

**DECLARATION - USA PATENT APPLICATION**

As a below named inventor, I hereby declare that:

My residence, post office address and citizenship are as stated below next to my name;

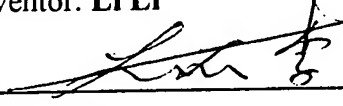
I believe I am an original, first and joint inventor of the subject matter which is claimed and for which a patent is sought on the invention entitled **CHEMICAL TREATMENT OF SEMICONDUCTOR SUBSTRATES**; the specification of which is attached hereto;

I hereby state that I have reviewed and understand the contents of the above identified specification, including the claims, as amended by any amendment referred to above;

I acknowledge the duty to disclose information which is material to patentability as defined in Title 37, Code of Federal Regulations, § 1.56;

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful, false statements may jeopardize the validity of the application or any patent issued thereon.

Full name of first inventor: **Li Li**

Inventor's signature 

Date 9/1/99

Residence: **2790 N. Oldstone Way, Meridian, ID 83642**

Citizenship: **P.R. China**

Post Office Address: **Same as above**

10027519-12001

---

Full name of Second inventor: <sup>Weimin</sup> ~~Micheal~~ Li <sup>(2)</sup>

Inventor's signature 

Date Sept. 1, 1999

Residence: 4616 Hale Street, Boise, ID 83706

Citizenship: P.R. China

Post Office Address: Same as above

---

Send Correspondence To:  
KNOBBE, MARTENS, OLSON & BEAR, LLP  
Customer No. 20,995

E:\DOCS\JWK\JWK-1624.DOC  
083199

1002519-122001  
FOO22T 6TS22001